

(Use several sheets if necessary.)

JUL 24 2001

PATENT & TRADE

09/903,764

2823

3. PATENT DOCUMENTS

[illegible]

FOREIGN PATENT DOCUMENTS


[illegible]

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

T. DANIS

10/9/02

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

	ATTY DOCKET NO. OKA-C104		SERIAL NO. 09/903,764
	OKU et al		
	FILING 07/13/2001	GROUP 2823	

U.S. PATENT DOCUMENTS

[illegible]

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Klausurfragen

DATE CONSIDERED

12/19/03

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Khiem Nguyen

DATE CONSIDERED

05/03/04

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